

(Modified) PFO/SB/08A-B (10-96)
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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(Modified) PTO/SB/08A-B (10-96) Approved for use through 10/31/99. OMB 0651-0031

Substitute for form 1449A-B/PTO		plet if Known
The state of the s	Application Number	09/920,452
IFORMATION DISCLOSURE	Act Piling Date	July 31, 2001
TATEMENT BY APPLICANT	First Named Inventor	Sun Ai Raillard
	Group Art Unit	1652
	Examiner Name	Richard G. Hutson
(use as many sheets as necessary)	Attorney Docket Number	0191.210US

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